SilcoNert.

The ultimate inert coating technology.

Previously known as Sulfinert® and Siltek®, the SilcoNert 2000 coating process results in a chemically protective barrier of amorphous silicon that is further functionalized to provide the ultimate inert surface. Applied via chemical vapor deposition (CVD), SilcoNert 2000 is ideal when trace-level testing accuracy (<PPM) of sulfurs, mercury, ammonia, or other active compounds is imperative.

SilcoNert 2000-coated parts may vary in appearance based on coating thickness and substrate material. All pictured samples (right) meet technical specifications, 100 - 500 nm.



SilcoNert[®] 2000 Properties

| Coating Composition: | Functionalized hydrogenated amorphous silicon |
|---------------------------------|--|
| Deposition Process: | Thermal chemical vapor deposition (not-plasma enhanced) |
| Maximum Temperature:* | Max for functionalization: 400°C (oxidative) 450°C (inert) |
| Substrate: | Compatibility: Stainless steel, exotic alloys, ceramics, aluminum Size: Typical parts up to 80" (203 cm), contact us for larger jobs Geometry: Any shape, including complex geometries |
| Typical Thickness: | 100 - 500 nm |
| Hydrophobicity (contact angle): | ≥65° |
| Allowable pH Exposure: | 0 - 8 |





Applications & Benefits

- Non line-of-sight process, all holes and complex geometries will be coated.
- Eliminate adsorption and retesting.
- Obtain faster calibrations.
- Gain full confidence in your analytical results.

Inert to Active Compounds

Inert to Sulfurs - Tubing coated with SilcoNert 2000 provides nearly instant sample response, requiring no priming of the analytical system.



Inert to Ammonia - Inertness enabled by SIIcoNert 2000 perimts 12x faster response than when using electroploished stainless steel.

Adsorption totals of ammonia on different substrates



Inert to Mercury - SilcoNert 2000 provides sample components excellent stability for mercury storage, even after weeks.



*SiltrideSM refers to the Siltride process, a thermal CVD that is performed on customer parts to have the properties identified above

Chemically Compatible

The functionalized silicon structure deposited by SilcoNert 2000 provides a highly inert barrier to analytes of interest.



High Temperature Stability

SilcoNert 2000 maintains its robust and inert properties up to 450° C, far exceeding the limits of PTFE.

Coating Temperature Limits



Non-Wetting

SilcoNert 2000 doubles the hydrophobicity of stainless steel and is commonly specified in moisture analyzer applications.



49°

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